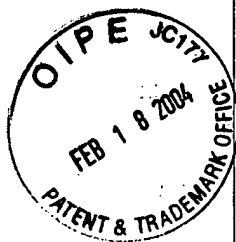


Image



PATENT
Customer No. 22,852
Attorney Docket No. 04329.2306

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
)
Yoshio Ozawa, et al.) Group Art Unit: 2823
)
Application No.: 09/559,757) Examiner: Pham, Thanh V.
)
Filed: April 27, 2000)
)
For: METHOD OF MANUFACTURING)
A SEMICONDUCTOR DEVICE)
USING AN OXIDATION)
PROCESS)

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

AMENDMENT

In reply to the Office Action of November 18, 2003, with the period for response extending through February 18, 2004, please amend the application as follows. Applicants also respectfully request the Examiner's reconsideration in view of the remarks that follow:

Amendments to the Claims are shown in the listing of claims beginning on page 2 of this paper.

Amendments to the Drawings are made in the attached replacement sheets and are discussed in the **Remarks** section of this paper.

Remarks begin on page 6.

Attachments to this paper include two (2) replacement sheets of drawings, including Figures 17 and 18.

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